

[10191/3964]

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant(s) : Franz LAERMER et al.  
Serial No. : To Be Assigned  
Filed : Herewith  
For : PLASMA SYSTEM AND METHOD FOR  
ANISOTROPICALLY ETCHING STRUCTURES INTO  
A SUBSTRATE  
Art Unit : To Be Assigned  
Examiner : To Be Assigned

Mail Stop PCT  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**PRELIMINARY AMENDMENT AND  
37 C.F.R. § 1.125 SUBSTITUTE SPECIFICATION STATEMENT**

SIR:

Please amend the above-identified application before examination, as set forth  
below.

**Amendments to the Specification** begin at page 2 of this paper.

**Amendments to the Claims** are reflected in the listing of the claims which begins  
at page 3 of this paper.

**Remarks** begin at page 7 of this paper.